

09/19/01

Class	Subclass	ISSUE CLASSIFICATION
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PATENT NUMBER

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U.S. UTILITY PATENT APPLICATION

O.I.P.E. <i>MR</i> SCANNED <i>NS 2</i> G.A. <i>JW</i>	PATENT DATE
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APPLICATION NO. 09/955126	CONT/PRIOR	CLASS 134	SUBCLASS 00	ART UNIT 1746	EXAMINER WINTER S. H. GLO
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LICANTS Keum Lee
Yong Ko
In Hwang

KORNAKOV

Method for cleaning damaged layers and polymer residue from semiconductor device

PTO-2040
12/99

PREPARED AND APPROVED FOR ISSUE

ISSUING CLASSIFICATION

ORIGINAL					CROSS REFERENCE(S)							
CLASS		SUBCLASS			CLASS	SUBCLASS (ONE SUBCLASS PER BLOCK)						
INTERNATIONAL CLASSIFICATION												
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<input type="checkbox"/> TERMINAL DISCLAIMER	DRAWINGS		CLAIMS ALLOWED	
	Sheets Drwg.	Figs. Drwg.	Print Fig.	Total Claims
<input type="checkbox"/> a) The term of this patent subsequent to _____ (date) has been disclaimed. <input type="checkbox"/> b) The term of this patent shall not extend beyond the expiration date of U.S Patent. No. _____ _____ _____	_____ (Assistant Examiner)		_____ (Date)	
	_____ (Primary Examiner) _____ (Date)		NOTICE OF ALLOWANCE MAILED	
<input type="checkbox"/> c) The terminal ____months of this patent have been disclaimed.	_____ (Legal Instruments Examiner) _____ (Date)		ISSUE FEE	
			Amount Due	Date Paid
		ISSUE BATCH NUMBER		
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(Rev. 10/97)

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